PATENT ABSTRACTS OF JAPAN

(11) Publication number: 2003115388 A

(43) Date of publication of application: 18.04.03

(51) Int. CI H05B 33/22 G02B 1/10 G02B 5/30 G09F 9/00 G09F 9/30 H01L 21/336

H01L 29/786

H05B 33/02 H05B 33/14

(21) Application number: 2001305862

(22) Date of filing: 01.10.01

(71) Applicant:

SEMICONDUCTOR ENERGY LAB

CO LTD

(72) Inventor:

YAMAZAKI SHUNPEI TAKAYAMA TORU

(54) LIGHT EMITTING EQUIPMENT AND ELECTRONIC DEVICE, AND ORGANIC POLARIZING FILM

(57) Abstract:

PROBLEM TO BE SOLVED: To provide light emitting equipment, which can suppress degradation by diffusion of impurities, such as moisture, oxygen, alkaline metals, and alkaline-earth metals, and specifically to provide flexible light emitting equipment which has OLED formed on a plastic substrate.

SOLUTION: The barrier films 14a and 14b, which consist of a layer shown by AlXNY, or a layer shown by AlXNY, or a layer shown by Al₂O₃, which prevent oxygen and moisture entering into the organic light emitting layer of OLED, and are possible to prevent impurities such as alkaline metals, alkaline-earth metals, and the like entering into an active layer of TFT, are provided with a single layer or two or more layers on a circular polarizing plate 15, in the light emitting equipment using the substrate 10.

COPYRIGHT: (C)2003,JPO

